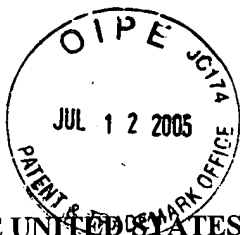


Docket No.: 4006-275



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Wen-Jian LIN

U.S. Patent Application No. 10/706,923

Filed: November 14, 2003

:
:
: Confirmation No. 7651
:
: Group Art Unit: 2873
:
: Examiner: JESSICA T. STULTZ

For: A METHOD FOR FABRICATING AN INTERFERENCE DISPLAY UNIT

Dear Sir:

Transmitted herewith is an Amendment in the above identified application.

- ☒ No additional fee is required.
☐ Small entity status of this application has been established.
☒ Also attached: Annotated and Revised Sheets of Drawings for Figures 6B and 6D

The fee has been calculated as shown below:

	NO. OF CLAIMS	HIGHEST PREVIOUSLY PAID FOR	EXTRA CLAIMS	RATE	FEE
Total Claims	8	20		x \$ 50 =	\$ 0.00
Independent Claims	1	3	0	x \$200 =	\$ 0.00
If multiple claims newly presented, add \$360.00					
Fee for extension of time					
TOTAL FEE DUE					\$ 0.00

- ☐ A credit card authorization form in the amount of _____ is attached
- ☒ The Commissioner is hereby authorized to charge payment of any *deficiency* in fees associated with this communication or credit any overpayment, to Deposit Account No. 07-1337, including any filing fees under 37 CFR 1.16 for presentation of extra claims and any patent application processing fees under 37 CFR 1.17.

Respectfully submitted,

LOWE HAUPTMAN & BERNER, LLP

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Date: July 12, 2005



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PATENT

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In re Application of	:	
Wen-Jian LIN	:	Confirmation No. 7651
U.S. Patent Application No. 10/706,923	:	Group Art Unit: 2873
Filed: November 14, 2003	:	Examiner: Jessica T. Stultz

For: A METHOD FOR FABRICATING AN INTERFERENCE DISPLAY UNIT

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This paper is in response to the Official Action mailed April 12, 2005. Applicants respectfully submit the following amendments and comments in connection with the above-named application.